PSG INSTITUTE OF ADVANCED STUDIES, COIMBATORE NANOTECH RESEARCH FACILITY

JOB REQUISITION FORM FOR MULTISOURCE PHYSICAL VAPOUR DEPOSITION SYSTEM WITH GLOVE BOX

Name:	Designation:			
Address:	Contact number:			
(Institution/Department)				
	Email ID:			
Supervisor:	Contact number:			
	Email ID:			
Internal (PSG)/External/Industry				
Number of depositions				
Is Co-deposition required? (tick any one) : YES/NO				

PVD Source	Description of Material to be deposited	Description of Substrate material	Desired film thickness	Co-sputtering/Co- evaporation required, if yes mention the different materials
Thermal Evaporation				
Electron beam evaporation				
RF Magnetron Sputtering				
DC Magnetron Sputtering				
RADAK				

This work is part of the research activity of the department / center. No remuneration or compensation is received from any agency. Further, it is certified that the sample(s) do not pose a health risk to anybody.

Date:	Signature of Researcher							
Recommendation of Supervi	sor :							
Signature of the Head of the Dept/Institution:								
	For lab	oratory use:						
Job priority: high/medium/lo								
Ref no: PSGIAS/cleanroomPVD/2014/		Date and time allotted:						
Job completed on date:	Remarks:							
Signature of faculty in-char	-ge							
Approval			Dir	ector, PSGIAS				
For office use								
Ref. No:	Date:							
Name and institution of the user								
Deposition (Technique)								
Deposition charges								
Payment details	DD/Cheque no.	Date	Bank name	Amount				
Name of the faculty who conducted the experiment								